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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Zhu et al.

Application No.: 10/733,858

Filed: December 10, 2003

Title: BIASED H₂ ETCH PROCESS IN
DEPOSITION-ETCH-DEPOSITION
GAP FILL

Attorney Docket No.:
NOVLP090/NVLS-002888

Examiner: Smith, Bradley

Group: 2891

Confirmation No. 7860

CERTIFICATE OF FACSIMILE TRANSMISSION

I hereby certify that this correspondence is being transmitted by facsimile to fax number 571-273-8300 to the U.S. Patent and Trademark Office on January 9, 2006.

Signed: _____

Natalie Morgan

AMENDMENT B (Filed with RCE)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

This amendment is being filed with a Request for Continued Examination and addresses the rejections made in the Final Office Action mailed October 7, 2005. Please consider the following remarks and amendments prior to taking further action on this application:

Amendments to the Claims are reflected in the listing of claims which begin on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.

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